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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Rivoire, et al.

Serial No.: 09/844,991

Filed: April 27, 2001

Confirmation No.: 1361

For: Method for Planarizing
Organosilicate Layers

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Group Art Unit: 3723

Examiner: Unknown

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TECHNOLOGY CENTER R3700

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Patent Counsel
Applied Materials, Inc.
P.O. Box 450A
Santa Clara, CA 95052

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Respectfully submitted,

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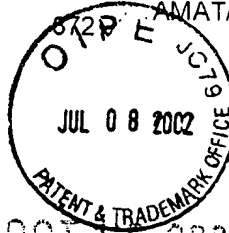
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APPLICATION NUMBER	FILING DATE	GRP ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO.	DRAWINGS	TOT CLAIMS	IND CLAIMS
09/844,991 ✓	04/27/2001 ✓	3723 ✓	AMAT/5297/DD/LOW K/JW ✓		2 ✓	29 ✓	3 ✓

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CONFIRMATION NO. 1361 ✓

UPDATED FILING RECEIPT



OC000000006866043

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Applicant(s)

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Assignment For Published Patent Application

Applied Materials, Inc.; ✓

TECHNOLOGY CENTER R3700

Domestic Priority data as claimed by applicant

Foreign Applications

If Required, Foreign Filing License Granted 06/21/2001

Projected Publication Date: 10/31/2002

Non-Publication Request: No

Early Publication Request: No

Title

COMPUTER ENTERED
OCT 16 2001

Method for planarizing organosilicate layers ✓

Preliminary Class

451

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